

**IN THE SPECIFICATION:**

Please amend page 5, paragraph 3, as follows:

(1) A thin film containing a photocatalyst semiconductor material is formed over the entire surface of the silicone rubber sheet 2. The photocatalyst semiconductor material is selected from a group consisting of  $\text{TiO}_2$ ,  $\text{ZnO}$ ,  $\text{SnO}_2$ ,  $\text{SrTiO}_3$ ,  $\text{WO}_3$ ,  $\text{Bi}_2\text{O}_3$  and  $\text{Fe}_2\text{O}_3$  (for further detail, see Japanese Patent No. 2756474, or corresponding U.S. Pat. No. 6,013,372 A, especially col. 10, line 41 to col. 12, and EP Pat. No. 0816466 A).